

PATENT
0465-0751P

IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant: KIM, Ha Zoong Conf.:
Appl. No.: New Group:
Filed: March 29, 2001 Examiner:
For: SEMICONDUCTOR DEVICE AND METHOD FOR
MANUFACTURING THE SAME

#5/Pre
amdt
a
11/7/01
VS

PRELIMINARY AMENDMENT

Assistant Commissioner for Patents
Washington, DC 20231

March 29, 2001

Sir:

The following preliminary amendments and remarks are respectfully submitted in connection with the above-identified application.

AMENDMENTS

IN THE CLAIMS:

Please amend the claims as follows:

6. (Amended) The method of claim 5, further comprising forming a mask on the semiconductor substrate such that the deep well areas are formed in the chip formation areas and not in the scribe lanes.

7. (Amended) The semiconductor device of claim 5, wherein,

D1
a'
Sub B2